



**PRESS RELEASE**

**FOR IMMEDIATE RELEASE**

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**First SF-100 ELITE System Delivered to the National Research Council of Canada**

Intelligent Micro Patterning, LLC, St. Petersburg, Florida, announced the sale of an SF-100 ELITE system to the National Research Council Canada (NRC) today. The SF-100 ELITE is a unique, maskless photolithography system that utilizes patented Smart Filter technology, licensed by Intelligent Micro Patterning, LLC from the University of South Florida. Smart Filter technology incorporates proprietary, cutting-edge, micro-optical techniques to rapidly project master images directly onto diverse substrate materials, such as semiconductors, quartz, ceramics, and plastics, without the use of photomasks. The main application of this system will be the development of microfluidics and photonic based devices.

Dr. Jay Sasserath, the Company's Chief Executive Officer, stated, "We are excited to have completed the installation of our first SF-100 ELITE system, especially at a location as prestigious as the NRC in Canada. We have a great relationship with the researchers there and look forward to a close collaboration together using the SF-100 ELITE."

"We are confident that the use of the maskless photolithography on the SF-100 ELITE system will greatly accelerate NRC's development programs", he added.

The SF-100 ELITE system reduces mask costs and provides data very quickly.

*For More Information, see the Intelligent Micro Patterning Website at [www.intelligentmp.com](http://www.intelligentmp.com)*